

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/707,726	01/07/2004	Toshiharu Furukawa	FIS920030316US1	1725
32074	7590 11/30/2004		EXAM	INER
INTERNA	TIONAL BUSINESS I	HU, SHOUXIANG		
DEPT. 18G BLDG. 300-482 2070 ROUTE 52 HOPEWELL JUNCTION, NY 12533			ART UNIT	PAPER NUMBER
			2811	
			DATE MAILED: 11/30/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	A It At Bl -	A				
	Application No.	Applicant(s)				
Office Action Comments	10/707,726	FURUKAWA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Shouxiang Hu	2811				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPL THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be time y within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	ely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 03 September 2004.						
· _ · · _ · · · · · · · · · · · · · · ·						
• •						
Disposition of Claims						
 4) Claim(s) 1-20 is/are pending in the application 4a) Of the above claim(s) 17-20 is/are withdray 5) Claim(s) is/are allowed. 6) Claim(s) 1-16 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or 	wn from consideration.					
Application Papers	•					
9) The specification is objected to by the Examine	er.					
10) The drawing(s) filed on is/are: a) □ accepted or b) □ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex						
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Burea * See the attached detailed Office action for a list	ts have been received. Is have been received in Application The rity documents have been received U (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)		·				
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 	Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	atent Application (PTO-152)				
S. Detect and Trademody Office						

DETAILED ACTION

Election/Restrictions

1. Claims 17-20 are withdrawn from further consideration pursuant to 37 CFR 1.142(b) as being drawn to a nonelected invention, there being no allowable generic or linking claim. Election was made without traverse in the reply filed on September 03, 2004.

Claim Rejections - 35 USC § 112

2. The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claims 6, 7, 11, 12, 15 and 16 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matters which were not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention. These claims recite the subject matters of "introducing a chemical constituent into the nanotube material during formation of one of the top and bottom of the nanotube to produce an electrical effect during operation", which are critical or essential to the practice of the invention as defined in these claims. However, the disclosure lacks an adequate description regarding what is the recited chemical constituent; how it is introduced into the recited

Art Unit: 2811

naotube's bottom and top sections inside the recited aperture; and how such process steps could be controllable.

Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 4. Claims 1-4, 8, 9 and 13 are rejected under 35 U.S.C. 102(e) as being anticipated by Roesner et al. ("Roesner"; US 6,740,910).

Roesner discloses a method of forming a vertical field effect transistor having a channel a carbon nanotube (see Figs. 1A-1C), comprising the steps of: forming a first conductive layer (102) on a substrate (101); forming a first insulating layer (103); forming a gate layer (104); forming an aperture (106), having substantially vertical interior walls, through the gate layer and the first insulating layer, the bottom of the aperture exposing the first conductive layer; forming an insulating liner (109) on the walls of the aperture; forming a catalyst (107); forming a semiconductive carbon nanotube (108) in the aperture, the bottom of the carbon nanotube being in electrical contact with the first conductive layer; and forming an electrical contact (110) on a top of the carbon nanotube.

Regarding claim 2, the method of Roesner including forming at least two FETs in a row.

Regarding claims 4, 8 and 13, the liner ---the gate insulating layer (109) in Roesner is formed thorough oxidation of the gate layer material (see col. 6, lines 24-31); and such a oxidation process step naturally involves an temperature-elevated environment.

Claim Rejections - 35 USC § 103

- 5. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 5-7, 10-12 and 14-16, insofar as being in compliance with 35. U.S.C. 112, are rejected under 35 U.S.C. 103(a) as being unpatentable over Roesner.

The disclosure of Roesner is discussed as applied to claims 1-4, 8, 9 and 13 above.

Although Roesner does not expressly disclose that: the insulating liner can be formed through CVD as recited in claims 5, 10 and 14; and/or that the channel forming nanotube can include LDD-type portions through changing the chemical compositions, one of ordinary skill in the art would readily recognize that such insulating liner functions as a gate insulating layer, which can also be readily formed through CVD for obtained good gate dielectric property, as evidenced in the prior art such as Yang (US 6,033,941;

Art Unit: 2811

see col. 1, lines 41-45), and/or Fitch et al. (US 5,414,289; see col. 4, lines 2-12); and that such LDD portions can desirably formed in FET for improving the channel performance therein, as further evidenced in Fitch et al. (see the LDD regions 27 and 32 in the cover page figure).

Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to make a vertical FET using the method of Roesner with the insulating liner being formed through CVD and/or with LDD portions being introduced into the nanotube, so that a method for forming a vertical FET with good quality on the gate insulating layer and/or with improved channel performance would be obtained.

Conclusion

6. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. References B-F are cited as being related to a device structure and/or a material set for a FET.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shouxiang Hu whose telephone number is 571-272-1654. The examiner can normally be reached on Monday through Thursday, 7:30 AM to 6:00 PM.

Application/Control Number: 10/707,726

Art Unit: 2811

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie C. Lee can be reached on 571-272-1732. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Page 6

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

СΗ

November 24, 2004

SHOUXIANG HU PRIMARY EXAMINER